## **Patent Abstracts of Japan**

**PUBLICATION NUMBER** 

2003041357

**PUBLICATION DATE** 

13-02-03

**APPLICATION DATE** 

27-07-01

**APPLICATION NUMBER** 

2001228005

APPLICANT: VESUVIUS FRANCE SA;

INVENTOR: CAILLAUD FREDERIC;

INT.CL.

: C23C 4/04 B22C 3/00 B22C 9/06 B22D 21/00 B22D 41/02 B22D 45/00 C04B 41/88

TITLE

: SILICON HOLDING VESSEL AND MANUFACTURING METHOD THEREFOR

ABSTRACT: PROBLEM TO BE SOLVED: To provide a vessel for holding molten silicon, which can effectively prevent contamination of a silicon melt, and is superior in sinterability, mechanical strength, and productivity, by coating the surface with thermal spraying.

> SOLUTION: This method for manufacturing the silicon holding vessel is characterized by coating an inner surface of the silicon holding vessel with a thermal sprayed film of silicon-based composite cermet consisting of metallic silicon, silicon nitride, and silicon oxide. The method for forming the above thermal sprayed film of the silicon-based composite cermet is characterized by spraying a silicon-based cermet material consisting of Si<sub>3</sub>N<sub>4</sub>, SiO<sub>2</sub>, and the metallic silicon as a binding material.

COPYRIGHT: (C)2003,JPO